## Crystal phase analysis of HZO thin film using ACOM-TEM

HZO (Hf<sub>0.5</sub>Zr<sub>0.5</sub>O<sub>2</sub>) is receiving a lot of attention as memory applications because of its ferroelectricity even in the thin film. Only orthorhombic crystals show ferroelectricity, so it is important to understand which crystalline phases are contained in HZO to determine the dielectric properties. This paper introduces an example of using ACOM-TEM to evaluate the crystalline phase ratio and other properties of HZO thin films.



ACOM-TEM: Automated crystal orientation and phase mapping in TEM (product name : ASTAR) Ferroelectric memory: FE-FET (Ferroelectric field effect transistor), etc.





The orthorhombic crystal ratio is 83%, and the average grain size is 26 nm

Toray Research Center, Inc. can fabricate TEM lamella of only HZO layer with a thickness of 10 nm taken from multi-stack structure and plan-view ACOM-TEM analysis can be performed. Our techniques can reveal the crystal phase ratios (tetragonal, orthorhombic, monoclinic) of HZO.

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